

## PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2000-164681

(43)Date of publication of application : 16.06.2000

(51)Int.Cl.

H01L 21/68

(21)Application number : 10-340913

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(22)Date of filing : 01.12.1998

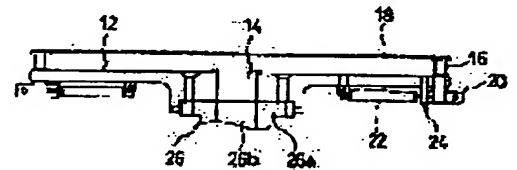
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## (54) RETAINING DEVICE OF CIRCULAR SUBSTRATE MEMBER AND ITS USAGE

## (57)Abstract:

**PROBLEM TO BE SOLVED:** To prevent the spray of chemicals or the like from adhering onto the lower surface of a circular substrate member by turning, and by bringing a displacement part being displaced toward the center side of a base member where a hollow hole is formed into contact with the circumference part of the circular substrate member for retaining the circular substrate member.

**SOLUTION:** In a base member 12 of a wafer-retaining device 10 being formed in a disk shape as a whole, a void 14 is formed at a center part. At the circumference part of the base 12, four wafer retention pins 16 are turnably provided. The wafer retention pin 16 is composed of a pin body, a conical part being subjected to eccentricity from the pin body, and an inverted conical part. When the base member 12 is turned clockwise, the inverted conical part retains a wafer 18. A unit for washing can be incorporated into the void 14 of the base member 12, and the lower surface of the wafer 18 can be sufficiently washed, thus effectively preventing the spray of chemicals, photoresist liquid, or the like from adhering to the lower surface of the circular substrate member.



## LEGAL STATUS

[Date of request for examination]

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the  
examiner's decision of rejection or application  
converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of  
rejection][Date of requesting appeal against examiner's decision  
of rejection]

[Date of extinction of right]

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